

PATENT Attorney Docket No. 203924

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

Kodama et al.

Application No. 09/502,834

Filed: February 11, 2000

For:

POLYBENZAZOLE ARTICLE AND PRODUCTION METHOD

THEREOF

Art Unit: 1711

Examiner: D. Truong

PENDING CLAIMS AFTER AMENDMENTS MADE IN RESPONSE TO OFFICE ACTION DATED JULY 10, 2001

- 1. A polybenzazole article superior in light resistance, which comprises a polybenzazole and a light-resisting agent that allows for a regular reflectance of the article of not more than 30% in not less than 30% of the wavelength region of from 450 nm to 700 nm, wherein the light-resisting agent comprises an aromatic amine or phenol with the proviso that the light-resisting agent does not comprise a dye.
- 2. The polybenzazole article of claim 1, wherein the light-resisting agent allows for a regular reflectance of the article of not more than 20% in not less than 10% of the wavelength region of from 450 nm to 700 nm.
- 3. The polybenzazole article of claim 1, which has a strength of not less than 35 g/d.
- 6. The polybenzazole article of claim 1, wherein the light-resisting agent is contained in a proportion of 0.01 to 20% by weight of the article.